

# Dust Networks

## Eterna™ Integration Guide



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# About This Guide

This document provides the design guidelines essential for incorporating an Eterna™-based design. The document covers design, layout, EMI, some device configuration and manufacturing considerations.

## Audience

This document is intended for system developers, hardware designers, and layout engineers.

## Related Documents

The following related documents are available:

[\*Eterna Integration Guide\*](#) (this guide)

[\*600- 0180 MASTER SCHEMATIC ETERNA MOTE EUPHRATES.pdf\*](#)

[\*600- 0180 MASTER SCHEMATIC ETERNA MOTE EUPHRATES.dsn\*](#)

[\*600- 0180 ETERNA MOTE EUPHRATES.pcb\*](#)

[\*Eterna Board Specific Configuration Guide\*](#)

[\*Eterna Serial Programmer Guide\*](#)

[\*605-0211 MASTER SCHEMATIC ETERNA MEMORY REFERENCE ELWHA.pdf\*](#)

[\*605-0211 MASTER SCHEMATIC ETERNA MEMORY REFERENCE ELWHA.dsn\*](#)

## Conventions and Terminology

This guide uses the following text conventions:

- Computer type indicates information that you enter, such as a URL.
- **Bold type** indicates buttons, fields, and menu commands.
- *Italic type* is used to introduce a new term.
- **Note:** Notes provide more detailed information about concepts.
- **Caution:** Cautions advise about actions that might result in loss of data.
- **Warning:** Warnings advise about actions that might cause physical harm to the hardware or your person.

## Revision History

Revision	Date	Description
040-0102 rev 1	5/6/2011	Initial Release
040-0102 rev 2	11/8/2011	Added QH072F1A Land Pattern Recommendations. Added Solder mask over pad recommendations for the 20 MHz xtal. Added recommendations for QH072F1A paddle solder stencil design.

		Corrected pin out for J3 Target SPI programming header.
<b>040-0102 rev 3</b>	2/9/2012	
<b>040-0102 rev 4</b>	7/18/2012	Added description for RF filtering options.
<b>040-0102 rev 5</b>	10/15/2012	Corrected BOM part number and value fields for C6 and C16.
<b>040-0102 rev 6</b>	12/14/2012	Added support of external memory and updated status of the crystal verification. Added warning for the use of the Fractus FR05-S1-N-0-102 chip antenna.
<b>040-0102 rev 7</b>	4/2/2013	Defined the differences between the -IPRA and -IPRB performance and configuration requirements.
<b>040-0102 rev 8</b>	5/8/2013	Added hyperlinks to published references.

# General Design Guidelines

## Schematic Design

The schematic shown in Figure 1 includes all the external connections and components necessary for the operation of a full-featured Eterna-based design. Please use the corresponding Bill of Materials (BOM), see Table 1, as the definitive reference for the part numbers and values.

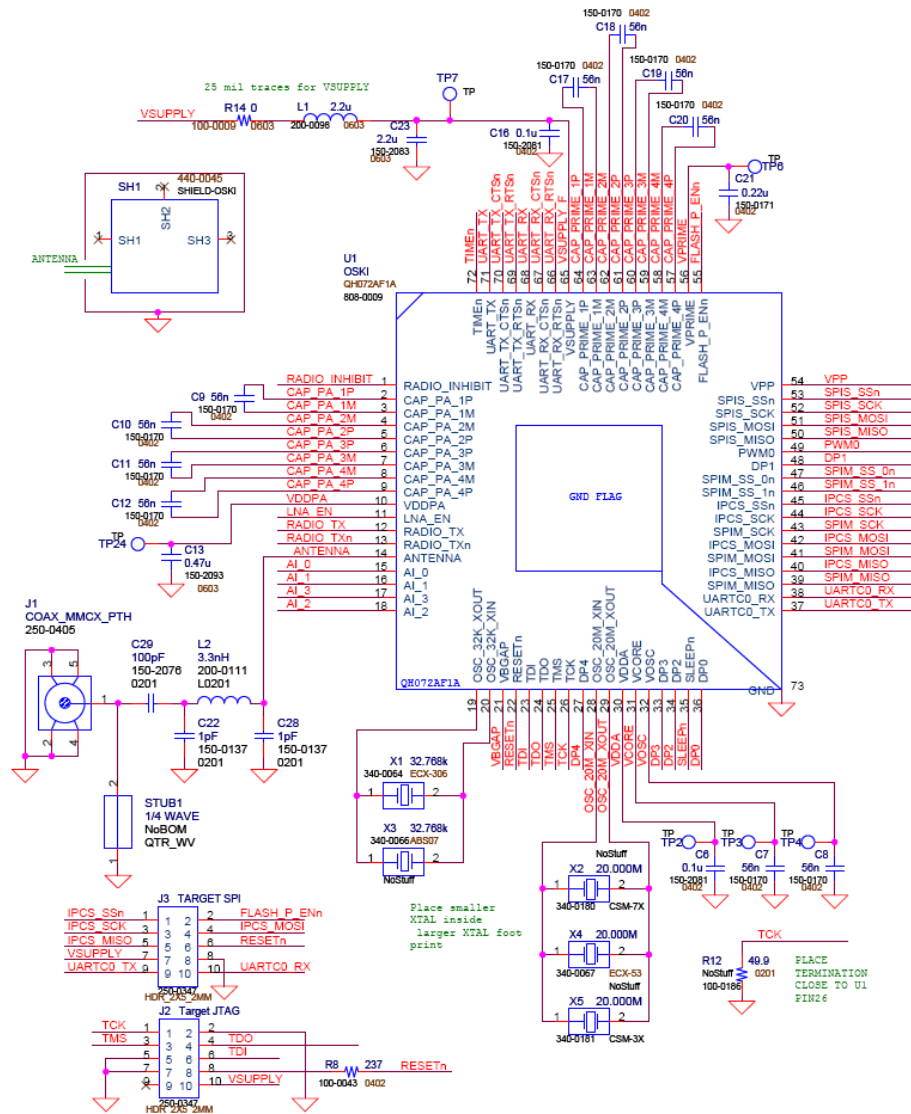


Figure 1 Eterna Example Schematic

The design includes power supply filtering via C23, C16, R14, and L1. The capacitor, C16, must always be included and must be a ceramic type (X7R is recommended for solutions requiring a wide temperature range and X5R otherwise) in order to support the high frequency transient currents on the Eterna power supply. Note that R12 is present to de-Q L1. The Eterna is most sensitive to supply noise in the 100 to 2000 kHz band. The included filter will reduce noise in the most sensitive band by roughly an order of magnitude and is not required for all supply designs. However, it is essential to meet the Eterna's power supply requirements for maximum noise considering both steady state operation and transient response.

An RF shield is typically required to obtain modular certification. However, it provides minimal benefit in typical environments in providing isolation from RF and magnetic fields.

Capacitors C6 through C13 and C16 through C21 are used for on chip regulation of power supplies and should be placed as close as possible to their corresponding package leads. These capacitors must be X7R. Capacitors C29, C22 and C28 are placeholders for a Pi matching network, where these components may be either capacitors or inductors as dictated by the match required. The values in the BOM represent the current matching required for a 50-Ohm load.

STUB1, connected to the RF path near the antenna connector is a  $\frac{1}{4}$  wave, at 2.44 GHz, microstrip terminated to ground. The  $\frac{1}{4}$  wave stub provides a notch filter at the 2<sup>nd</sup> harmonic, enabling Eterna to easily meet world wide certification requirements while only having slight impact on radio performance. The use of the  $\frac{1}{4}$  wave stub significantly improves ESD performance while having near zero cost and is the preferred approach to lowering the 2<sup>nd</sup> Harmonic emissions. **Warning:** The Fractus FR05-S1-N-0-102 chip antenna has demonstrated high gain lobes when used in combination with a  $\frac{1}{4}$  wave stub which may prevent a design from passing radio certification. When using the Fractus FR05-S1-N-0-102, ESD the Pi-filter comprising L2, C22 and C28 should be used. When using a  $\frac{1}{4}$  wave stub designs need not incorporate L2, C22 and C28; however, conservative practice would be to include the layout supporting those components and loading L2 with a 100 pF capacitor (this allows for matching and additional filtering should it be necessary). Should layout considerations prevent the use of a  $\frac{1}{4}$  wave stub, a low pass Pi-filter comprised of L2, C22 and C28 may be used. Board stack up should be chosen such that the trace width of the RF path, a 50 ohm impedance, is equal to or near the pad side for the 0201 components.

**Table 1 Sample BOM**

Reference	Value	Vendor	Vendor P/N
R14	0	Yageo	RC0603JR-070RL
R8	237	Vishay	CRCW0402237RFKED
C7, C8, C9, C10, C11, C12, C17, C18, C19, C20	56 nF	Kemet	C0402C563K9RACTU
C21	220 nF	Taiyo Yuden	JMK105B7224KV-F
C22*, C28*	1 pF	Murata	GRM610C0G010B25K500
C29	100 pF	Murata	GRM0335C1E101JD01D
C6,C16	100 nF	Murata	GRM155R71C104KA88D
C23	2.2 $\mu$ F	Murata	GRM188R71A225KE15D
C13	470 nF	TDK	C1005X5R0J474K
L1	2.2 $\mu$ H	Murata	LQM18FN2R2M00D

Reference	Value	Vendor	Vendor P/N
L2*	3.3 nH 0201 or 2.7 nH 0402	Coilcraft Coilcraft	0201DS-3N3XJL 0402CS-2N7XJL
J1		JST	AYU1-1P-02676-120
X1	32.768 kHz	ECS Inc.	ECS-.327-12.5-17X-TR
X2	20.000 MHz	ECS Inc.	ECS-200-CDX-0914
J2, J3	5x2 header	Molex	87831-1020
SH1		Fotofab	Dust Networks 440-0045

Note: \* - these components are not needed if a ¼ stub is implemented.

## Crystal Selection

The 20 MHz source (either X2, X4 or X5 on the schematic) is required for radio operation. The 32 kHz source, either X1 or X3 on the schematic, is required for long term precise timing. For mesh network applications, selection of crystal sources is significant as Eterna mesh networks depend on maintaining timing more precise than provided by the crystal accuracy itself. While alternate sources for the 20 MHz and 32 kHz crystals will be supported, it is strongly recommended that designs incorporate crystals from Table 2 and Table 3 below, such that the designs will benefit from the verification performed against those crystals. Network performance for unverified crystals can not be guaranteed.

**Table 2 20 MHz Crystals**

Vendor	Part Number	Form Factor
<b>ECS</b>	<b>ECS-200-CDX-0914</b>	<b>7.6x4.1x2.3mm, SMD</b>
Abrakon	TBD	12.7x4.7x3.3mm, SMD
ECS	TBD	3.2x1.5x0.9mm, SMD
Abrakon	TBD	3.2x1.5x0.9mm, SMD

\*\* Crystals in bold have completed verification, crystals in italics are currently being tested and the remaining crystals have yet to be tested.

**Table 3 32 kHz Crystals**

Vendor	Part Number	Form Factor
<b>ECS</b>	<b>ECS-.327-12.5-17X</b>	<b>8.7x3.7x2.5mm, SMD</b>
Abrakon	ABS25-32.768KHZ-4-T-ND	8.0x3.8x2.5mm, SMD
ECS	ECS-.327-12.5-34B	3.2x1.5x0.9mm, SMD
Abrakon	ABS07-32.768kHz-4-T	3.2x1.5x0.9mm, SMD

## System Configuration

Eterna supports hardware and software configuration of devices via two tables stored in the first page of Eterna's flash. These configurations are set by creating a 2kB image via the Eterna Board Specific Configuration application described in the [Eterna Board Specific Configuration Guide](#) and written to Eterna's flash via the Eterna Serial Programmer described in the [Eterna Serial Programmer Guide](#).

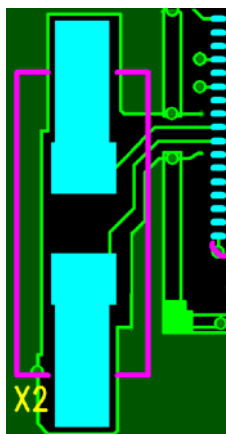


Eterna includes a hardware engine for configuring the device immediately on exit from power-on reset and is the preferred method for configuring the multifunction IO. Configuration controls include the mapping of pins to functions, setting drive strength, IO direction, GPIO output value, pull enable, pull direction, and input enable. In addition the Eterna's Hardware lock key, a user defined key that locks all external access (including debug access) to flash and RAM memory, can be set via the Eterna Board Specific Configuration application. The Eterna Board Specific Configuration application inherently provides an expedient method to map out the functions assigned to Eterna's multifunction IO, greatly reducing the need to manually cross reference multiple tables in the product's data sheet.

## PCB Layout

Eterna-based designs should adhere to the following layout-sensitive guidelines:

1. The trace from the ANTENNA pin to the antenna connector should be 50-Ohm characteristic impedance. Note that the drawn trace width will be a function of the dielectric constant, height of the dielectric and the thickness of the plating. For example, for an 8-mil FR4 substrate with 0.5 oz copper plating, the width for a 50-Ohm trace is 14.5 mils. Keep all other active signals as far as possible from this trace and at least five times the dielectric height to the RF ground plane. No signals should be routed between this trace and its respective ground plane.
2. The ground return for the ANTENNA pin is through the QFN paddle. The layout should ensure that at least a 25 mils wide ground (and preferably as wide as practically manageable) continues in a straight line through to the points where the paddle is via stitched to ground.
3. Capacitors C6 through C13 and C16 through C21 should be placed no further than 250 mils from their respective leads. All power supply traces for VSUPPLY, VPRIME, VDDPA, VOSC, VCORE and VDDA should be a minimum of 25 mils wide.
4. Noise from other digital signals can couple onto the 20 MHz crystal reference and impair the radio performance. Traces from the 20 MHz crystal should be routed on the same outside layer as the Eterna QFN, with no overlap from any other signal, as shown in Figure 2. The adjacent layer on the PCB shall provide a ground plane, isolating the crystal traces from other traces on the PCB. The crystal leads and the corresponding traces should be surrounded by a co-planer ground trace to reduce coupling onto the crystal pads and traces. If a shield is present in the design the signals should rout through an opening in the exposed metal trace described in the RF shield section below.



**Figure 2 Sample 20 MHz Crystal Routing**

5. Noise from other digital signals can couple onto the 32-kHz crystal reference creating timing jitter for the low frequency clock. Traces from the 32 kHz crystal should be routed on the same outside layer as the Eterna QFN, with no overlap from any other signal. The adjacent layer on the PCB shall provide a ground plane, isolating the crystal traces from other traces on the PCB. If a shield is present in the design the signals should rout through an opening in the exposed metal trace described in the RF shield section below.

6. In applications where EMI necessitates the inclusion of an RF shield, a thick outside layer exposed metal trace, tapped to ground approximately every 100 to 250 mils, should encircle (save the path for the antenna and crystal signals) the device. Determination for the size of the shield should account for the routing challenges placed due to the limited area to create vias from the outside layer with the QFN to other layers for routing. The shield will create a bounding box on the outside with the QFN paddle will create an internal bounding box. Also, consider the number of connections that should be as short as possible for the required power supply components that should be placed near the QFN leads.
7. The recommended land pattern for the smaller footprint crystals, 3.2mm x 1.5mm, includes pads that are much wider than the crystal leads. Creating a dual footprint for both the large and smaller form factor 20 MHz crystals further enlarges the pad size. The large pad size can result in crystals drifting from their placement during the reflow process. Reducing the pad size reduces a design's robustness to vibration, which could be an important factor given the mass of either the larger 20 MHz crystals. With the purpose of reducing the drift of the crystal during the reflow process, it is recommended to include additional solder mask over the pad as show in red in Figure 3.

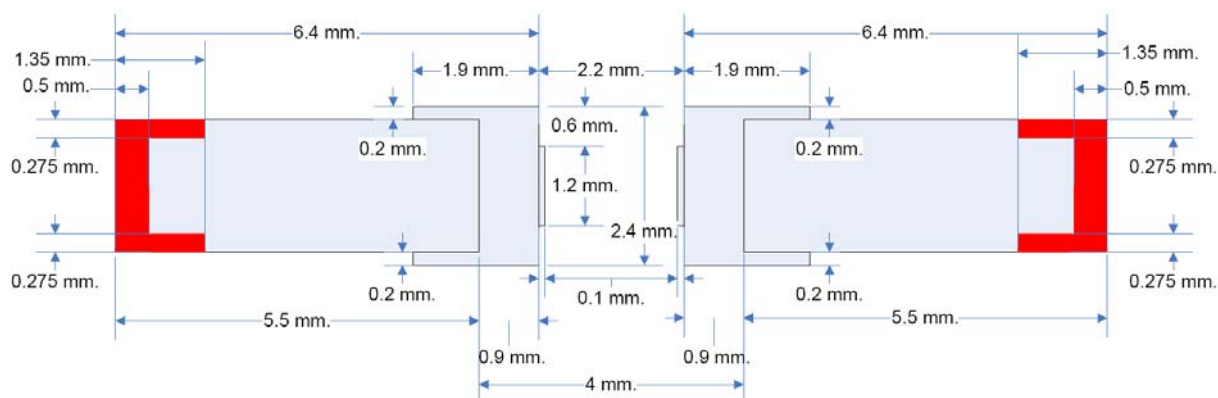


Figure 3 Triple 20 MHz crystal footprint with solder mask over pad

An example layout corresponding to the provided example schematic, can be found in [600-0180 ETERNA MOTE EUPHRATES.pcb](#), a PADs formatted PCB file and it's corresponding gerber files.

## Eterna QFN 72 Lead Recommended Land Pattern (QFN package QH072AF2A)

Two common practices for defining land patterns are Non Solder Mask Defined, NSMD, and Solder Mask Defined, SMD. Given the lead pitch of the QH072AF2A package and that tolerances for metal etch are commonly more precise than solder mask deposition, the use of NSMD land patterns is recommended and documented here. The solder mask opening should provide sufficient margin for registration tolerance to avoid solder mask infringing on the pad, typically 60 to 75 um from the edge of the pad and the solder mask. **Note that the lead length for the corner leads are shorter than the non-corner leads.**

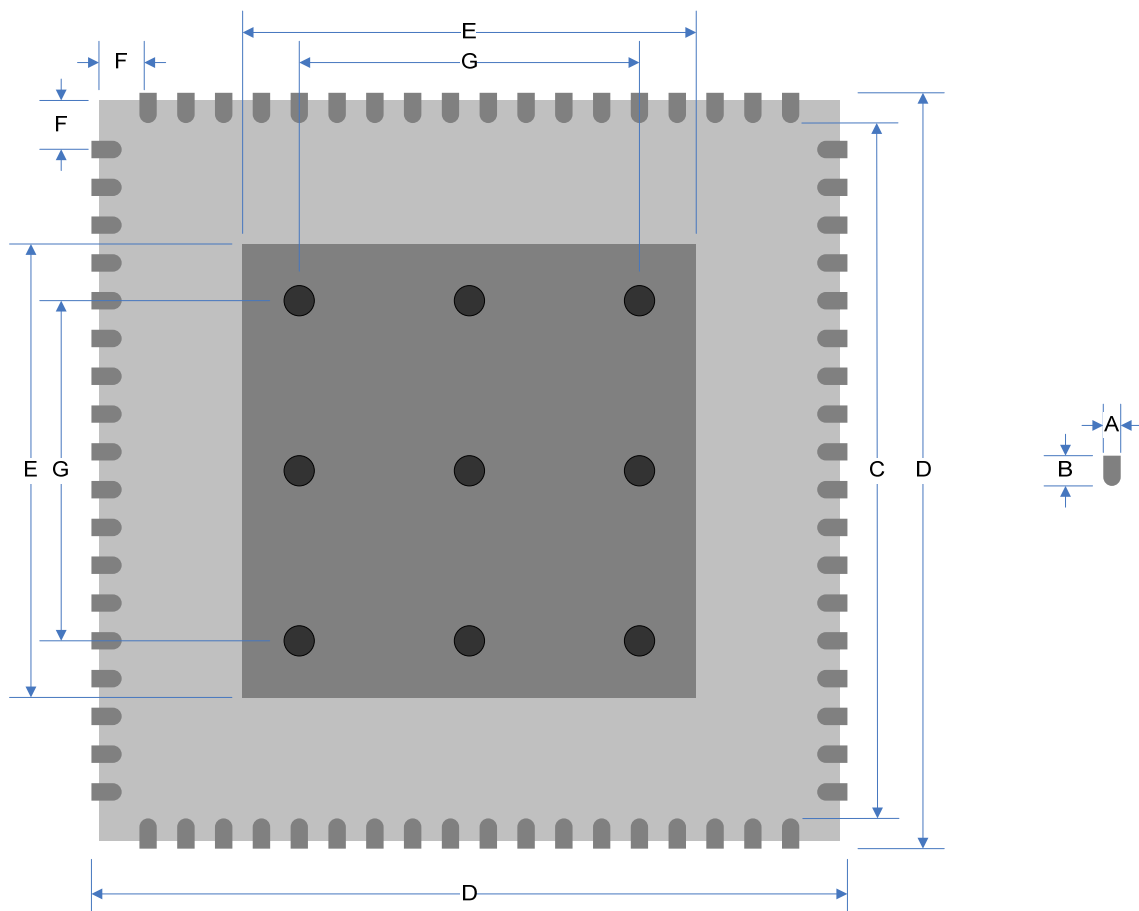
While Eterna does not require the ground paddle to dissipate significant thermal energy, the paddle provides the RF return path and should both be low inductance and provide a path near the ANTENNA pin for a return path. A pattern of 3 x 3 vias separated over a 4.5 mm x 4.5 mm square is recommended. Vias should be plugged with epoxy or tented to avoid solder wicking into the plated through holes,

potentially resulting in low package standoff height or secondary reflow on the reverse side of the PCB.

Land Pattern and Via placement dimensions are provided in Table 4 and illustrated in Figure 4.

**Table 4 Recommended Land Pattern Dimensions**

Symbol	Description	Dimension (mm)		
		Min	Typ	Max
A	Lead land width	0.25	-	0.29
B	Lead land length	0.85	-	-
	Corner Lead land length	0.75	-	-
C	Lead land pad inside dimension	8.70		8.80
	Corner lead land pad inside dimension	8.90		9.00
D	Lead land pad outside dimension	10.50	-	-
E	Ground paddle land width	6.15	-	-
F	Center first lead to package edge	-	0.75	-
G	Ground via spacing center to center	-	4.5	-



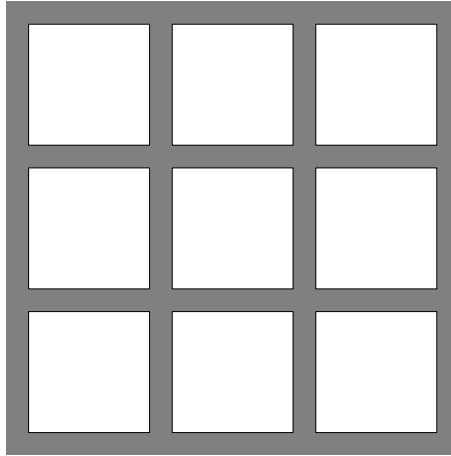
**Figure 4 72 Lead QFN Land Pattern (QFN package QH072AF2A)**

### **Stencil Design for Ground Paddle (QFN package QH072AF2A)**

As the Eterna (QH072AF2A QFN) includes a 6 x 6 mm ground paddle, appropriate care should be taken in designing the solder stencil. Large apertures in the solder stencil can lead to:

- 1) inadequate solder paste due to “scooping”
- 2) splatter and solder balling as a result of outgassing
- 3) increased standoff mismatch between leads on a QFN package
- 4) solder bridging

It is recommended to use smaller openings separated by at least 0.2 mm, with a coverage of between 50 and 80%. An example of such a stencil with 1.6 mm squares separated by 0.3 mm, providing 64% coverage is shown in Figure 5.



**Figure 5 Ground Paddle Stencil**

## EMI Considerations

Like all radio devices, Eterna can be sensitive to EMI. In cases where the deployment environment is known to have very low EMI, both in and out of band, the RF shield may not be necessary. It should be noted; however, that for modular radio certifications, regulatory bodies regularly require an RF shield. The following considerations should be taken into account when selecting an RF shield for an Eterna based design:

1. The RF shield should provide at least 0.5 mm (20 mils) clearance around the Eterna package in the X and Y dimensions.
2. The RF shield should provide 1 mm (40 mils) of clearance above the top of the PCB to the inside of the shield.
3. The RF shield should have a minimum of three asymmetric through hole pins. In vibration intensive use cases, a minimum of four through hole pins should be used and the RF shield should mate those pins to plated mounting holes and the majority of the shield perimeter should be soldered to the PCB.
4. Ideally, the RF shield should allow for the smallest opening, but still greater than 5 times the dielectric thickness between the antenna trace and the ground plane from edge/top of the antenna trace to the nearest edge of the shield, for the antenna signal to exit on the top layer of the PCB. This needs to be traded-off against the cost of manufacture, including the ability to clean the PCB underneath the shield.
5. In environments with high AC and DC magnetic fields, the use of a mu-metal shield is recommended. Further, RF shield thickness is application dependent. Consult your Linear FAE for support.

## Antenna ESD Considerations

The antenna pin is a particularly sensitive node for electro-static discharge (ESD) since it must detect small, high-frequency signals. ESD damage to the Eterna may result in decreased receive or transmit performance, or other system failure. Many applications for the Eterna have an exposed antenna that provides an entry point for ESD events. Proper consideration of antenna design as well as antenna protection can substantially improve ESD robustness in harsh environments.

A radome (protective covering) made of highly resistive material may be used to prevent direct contact with the antenna and/or dissipate charge. To avoid ESD events caused by triboelectric charging generated by wind passing over the antenna in dry climates, the radome design should consider bulk and surface resistivity as well as the size of the gap between the antenna metal and the interior of the radome.

In general, DC-grounded antennas (the antenna and ground have a DC short) provide superior protection to ESD events. DC-grounded antennas are highly recommended in harsh environments. Additionally, a DC path-to-earth ground should be provided whenever possible to help bleed off accumulated charge from the antenna as well as leak charge from the radome.

While these general guidelines should improve robustness to ESD events, individual implementations may have unique factors that complicate ESD protection. Upon request, your Linear FAE can provide contact information for an external consultant able to perform a review for ESD and other system considerations.

## Supply Design

Due to the heavy duty cycling, the Eterna's current consumption can change substantially over a short period. This does not represent an issue for systems with supplies having low source impedance (less than 5 Ohms). Regulated supplies, however, may have difficulty in the sudden changes in current consumption (more than an order of magnitude in less than 1  $\mu$ s), resulting in transient voltages on the supply co-incident with the higher current consumption of the radio operation. To ensure proper operation of the radio, a supply should be able to ramp from 250  $\mu$ A to 10 mA in less than 1  $\mu$ s without generating a transient greater than 200 mV. For systems with regulated supplies, consultation with your Linear Technology FAE is strongly recommended.

The Eterna can be configured to support current limited supplies. Contact your Linear FAE for details.

## Voltage Supervision and Reset

The Eterna includes a power-on reset to safely set its own state during power up, and includes a brown-out circuit that immediately halts flash erase cycles and interrupts flash write cycles at the next 32-bit boundary, generating an interrupt to the CPU and maintaining state for the CPU to correct should the power supply return to normal operating levels. In the interest in avoiding flash corruption, it is not considered best practice to connect the Eterna RESETn lead to a voltage supervisor or to asynchronously assert RESETn without previously suspending network and flash activity.

## Design for Manufacture

The schematic shown in Figure 1 includes a header, J3, intended to provide an interface to allow programming the Eterna. A mechanism to program the Eterna for manufacturing is needed and prudent for design development. The header provides connectivity through a cable to the DC9010 USB serial programmer described in the [\*Eterna Serial Programmer Guide\*](#). Software provided for controlling the programmer allows users to program and verify pages in flash, and optionally the entire flash contents. Note that the DC9010 programmer has a limited capability for supplying current to the DUT – see the Specifications section of the [\*Eterna Serial Programmer Guide\*](#) for details. A BDSL file for the LTC5800 can be found [here](#).



# External Memory Support

Without the addition of external SRAM, Eterna IP managers are limited to supporting networks of 32 or fewer motes. External memory may be added to Eterna IP Manager products to:

- 1) manage networks of up to 100 motes – and / or –
- 2) increase throughput of the manager from 24 to 36 packets per second

The LTC5800-IPRA is limited to supporting 32 motes with or without external RAM; however, a license key can be purchased to raise the limit to 100 motes, provided the external RAM is populated. To obtain a license key, a certificate must first be purchased. Contact your Linear Sales representative for details on how to order license key certificates. The certificate contains a product key and instructions for requesting the generation of a license key, which typically takes one to two business days to receive a license key. License keys are entered via either the **set config** command documented in [SmartMesh IP Manager CLI Guide](#) or the **setLicense** command documented in the [SmartMesh IP Manager API Guide](#). The LTC5800-IPRA by itself has a maximum sustained throughput of 24 packets per second. The LTC5800-IPRB with external SRAM support has a maximum sustained throughput of 36 packets per second.

The LTC5800-IPRB supports networks of up to 100 motes and has a maximum throughput of 36 packets per second; however, external RAM must be provided.

## Schematic Design

The schematic shown in Figure 6 and Figure 7 includes all the external connections and components necessary to add the external RAM. The schematic differs from the base schematic shown in Figure 1 in that:

- 1) CLI access is on UARTC1, not UARTC0
- 2) Mapping of external bus signals to Eterna's general purpose function pins
- 3) The Memory, latches and pulse generators shown in Figure 7

The reference Bill of Materials (BOM) for the addition components needed for the external memory interface is shown in Table 1.

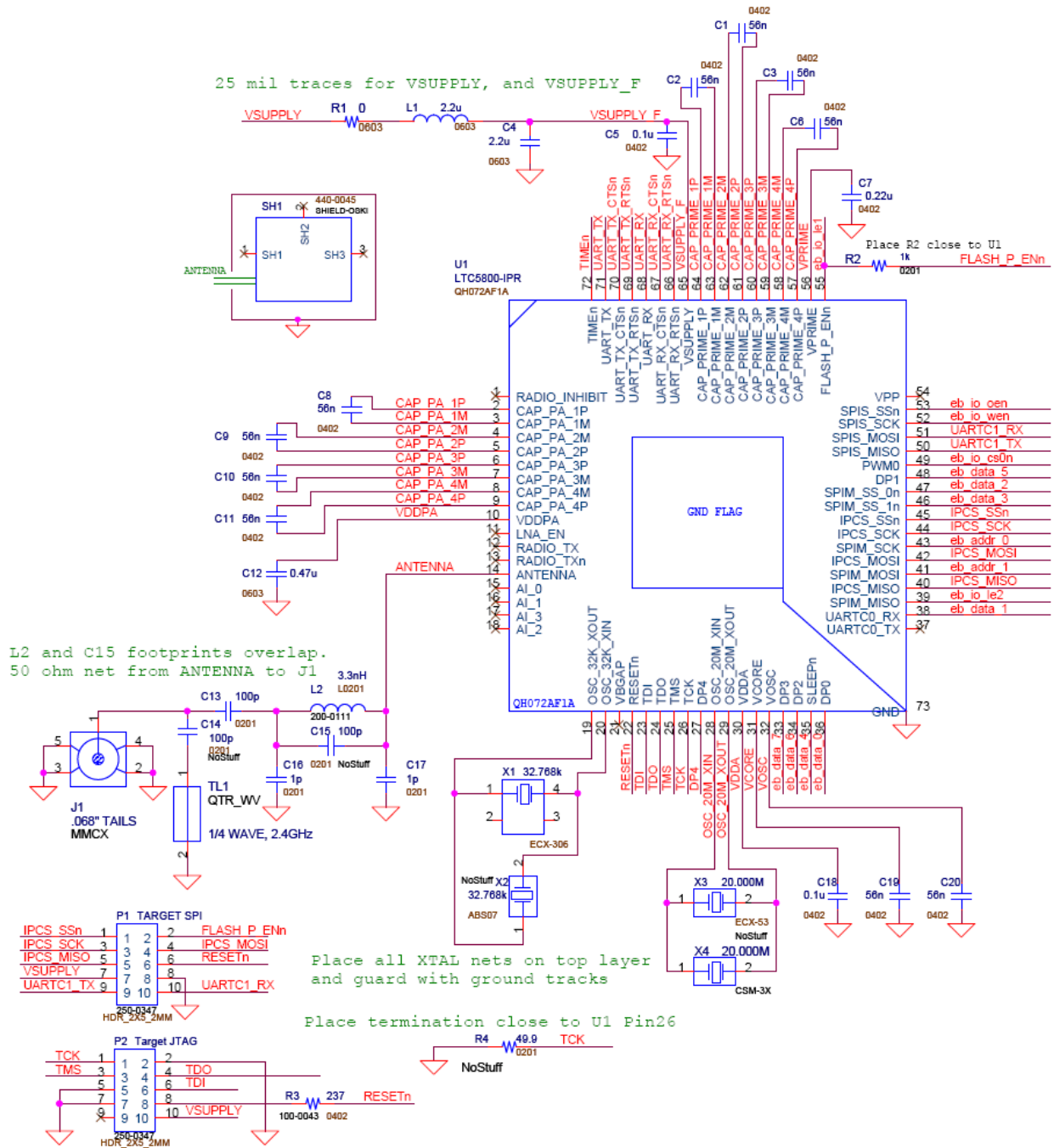


Figure 6 Eterna Extended Memory Example Schematic (page 1 of 2)

25 mil traces for VSUPPLY\_M

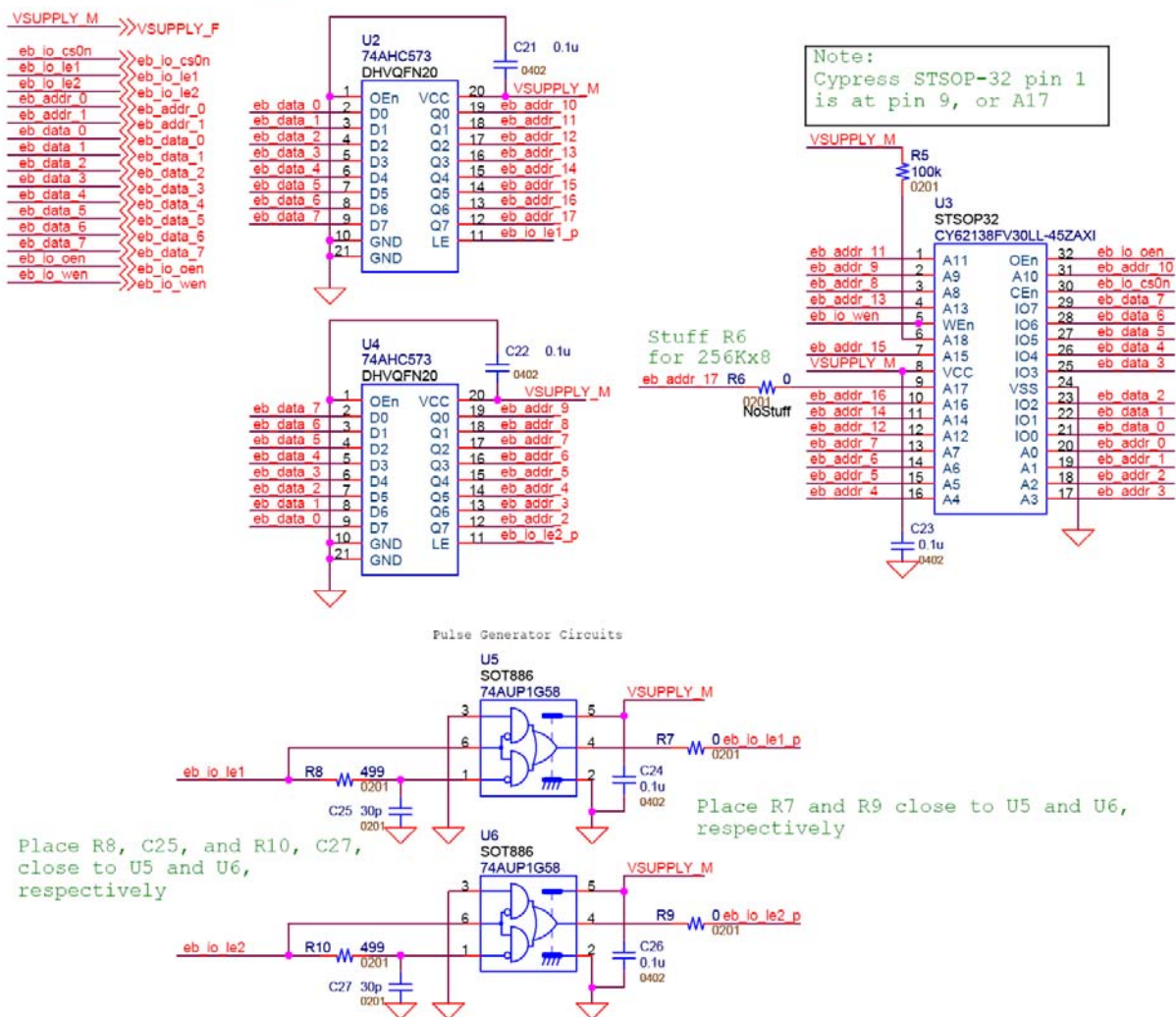


Figure 7 Eterna Extended Memory Example Schematic (page 2 of 2)

Eterna's External memory function has been tested with the BOM options shown in Table 5. The RAM components shown have been selected for low power operation and their use will result in an increase of a few uA of current consumption. For designs that are not energy constrained, substitution of general purpose RAMs with equal or faster speed grades should be possible. Substitution of the multi-function logic and octal latch components should be done carefully to maintain the timing generated by the pulse generation circuits.

Table 5 External Memory Reference Bill of Materials

Reference	Value	Vendor	Vendor P/N
R6,R7,R9	0	Panasonic	ERJ-1GE0R00C
R5	100 kOhm	Panasonic	ERJ-1GEJ104C
R8,R10	499 Ohm	Vishay	CRCW0201499RFKED
C25,C27	30 pF	Murata	GRM0335C1E300JD01D
C21,C22,C23, C24,C26	100 nF	Murata	GRM155R71C104KA88D

Reference	Value	Vendor	Vendor P/N
U3	128K x 8-bit RAM	Cypress	CY62128EV30LL-45ZAXI
U3 Alternate	128K x 8-bit RAM	Renasas	R1LV0108ESA-5SI#B0
U5, U6	Multifunction Logic	NXP	74AUP1G58GM, 132
U2, U4	Octal Latch	NXP	74AHC573BQ,115

logic and octal latch components should be done carefully to maintain the timing generated by the pulse generation circuits.

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## Device Configuration

Per the [Eterna Board Specific Configuration Guide](#), the LTC5800-IPRA or LTC5800-IPRB must have both the IO configured and the board support parameters set to function correctly. The IO is configured by enabling the “External Bus” check box on the IO Configuration page. On the “Board Support Parameters” page the “CLI Port Selection (0x03)” check box must be checked and the “UARTC1” option must be set in the selection box. In addition, the “IP Manager Ext. Memory Size (0x17)” check box must be checked and the appropriate LTC –dash option / memory foot print option must be set in the selection box. Please see the [Eterna Board Specific Configuration Guide](#), for complete details on all of the IO Configuration settings and Board Support Parameters.

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